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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR			TORNEY DOCKET NO.
09/116,3	95 07/16/98	OBSZARNY		C	FI9-97-288
DELIO & PETERSON 121 WHITNEY AVENUE NEW HAVEN CT 06510		MM91/0320 🎵	7 .	EXAMINER	
				KIM,F	•
			[ART UNIT	PAPER NUMBER
				2851	

Please find below and/or attached an Office communication concerning this application or proceeding.

Commissioner of Patents and Trademarks

03/20/00

Office Action Summary

Application No. 09/116,395 Applicant(s)

Examiner

PETER KIM

Group Art Unit 2851

Obszarny



X Responsive to communication(s) filed on Feb 11, 2000			
☐ This action is FINAL.			
☐ Since this application is in condition for allowance except for in accordance with the practice under <i>Ex parte Quayle</i> , 193	or formal matters, prosecution as to the merits is closed 35 C.D. 11; 453 O.G. 213.		
A shortened statutory period for response to this action is set is longer, from the mailing date of this communication. Failure application to become abandoned. (35 U.S.C. § 133). Extens 37 CFR 1.136(a).	to respond within the period for response will cause the		
Disposition of Claims			
	is/are pending in the application.		
Of the above, claim(s)	is/are withdrawn from consideration.		
Claim(s)	•		
	is/are rejected.		
Claim(s)			
☐ Claims			
Application Papers			
☐ See the attached Notice of Draftsperson's Patent Drawin	ng Review, PTO-948.		
☐ The drawing(s) filed on is/are object	cted to by the Examiner.		
☐ The proposed drawing correction, filed on	is □approved □disapproved.		
☐ The specification is objected to by the Examiner.			
☐ The oath or declaration is objected to by the Examiner.			
Priority under 35 U.S.C. § 119	·		
☐ Acknowledgement is made of a claim for foreign priority			
☐ All ☐ Some* ☐ None of the CERTIFIED copies	of the priority documents have been		
☐ received.			
 received in Application No. (Series Code/Serial Nu received in this national stage application from the 			
*Certified copies not received:			
☐ Acknowledgement is made of a claim for domestic prior			
Attachment(s)			
☑ Notice of References Cited, PTO-892			
☐ Information Disclosure Statement(s), PTO-1449, Paper N	lo(s)		
☐ Interview Summary, PTO-413			
☐ Notice of Draftsperson's Patent Drawing Review, PTO-9	48		
☐ Notice of Informal Patent Application, PTO-152			
SEE OFFICE ACTION ON	THE FOLLOWING PAGES		

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DETAILED ACTION

1. Applicant's arguments filed on 2/11/00 (paper #9) have been fully considered.

Claim Rejections - 35 USC § 112

2. The following is a quotation of the second paragraph of 35 U.S.C. 112:

The specification shall conclude with one or more claims particularly pointing out and distinctly claiming the subject matter which the applicant regards as his invention.

3. Claims 1-9 are rejected under 35 U.S.C. 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention.

In Claims 1 and 7, "the optical transmission" and "the contrast" lack proper antecedent basis.

The remaining claims, not specifically mentioned, are rejected for incorporating the defects from the base claim by dependency.

Claim Rejections - 35 USC § 103

- 4. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

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5. Claims 1, 2, 4, 5, 7-9, 17 and 18 are rejected under 35 U.S.C. 103(a) as being unpatentable over Chiu in view of Tanabe.

Chiu discloses an apparatus for exposing a substrate with a light source (ref. 122) a photomask (ref. 10) impregnated with a thin layer of polymer, first polarizer (ref. 55) and second polarizer (ref. 60), focusing optics for concentrating the light the first polarizer and reducing optics (ref. 128) to focus the light on the substrate wafer (ref. 130). However, Chiu does not disclose the first polarizer that is capable of adjustment during the optical transmission. Tanabe discloses an apparatus for exposing a substrate with a polarizer (ref. 101) capable of adjustment during the optical transmission, a photo mask (ref. 22) patterned with a plurality of optically transparent and optically opaque regions and an electromagnetic radiation beam image reducing means to reduce and focus the diffraction pattern on the substrate. Although Tanabe does not explicitly state the transmissivity level of 0.1%, it is well known that metal layer such as chromium has very low transmissivity level of 0.1% or lower. Therefore, it would have been obvious to a person of ordinary skill in the art at the time the invention was made to provide the adjustable polarizer of Tanabe instead of the first polarizer attached to the mask in order to control the polarization direction of light.

6. Claims 3 and 6 are rejected under 35 U.S.C. 103(a) as being unpatentable over Chiu in view of Tanabe as applied to claim 1 above, and further in view of Okamoto et al. (Okamoto).

The further difference between the claimed invention and the modified Chiu is the photo

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mask with a spin-on-glass layer for phase shifting and a patterned metal layer for blocking transmission. Okamoto discloses an exposure apparatus with a photo mask with a patterned spin-on-glass layer for phase shifting and a patterned metal layer made of chromium for blocking transmission. Therefore, it would have been obvious to a person of ordinary skill in the art at the time the invention was made to further modify Chiu with the photo mask of Okamoto in order to obtain phase shifting necessary for the contrast adjustment.

Remarks

7. Due to applicant's arguments against the Matsumoto reference, Matsumoto is withdrawn and Chiu in view of Tanabe is used in rejection. Applicant argues that Okamoto does not use spin-on-glass layer for polarizing but for phase shifting. However, the wording of the claim is "spin-on-glass layer for phase shifting."

Conclusion

- 8. All claims are rejected.
- 9. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Peter Kim whose telephone number is (703) 305-0105. The examiner can normally be reached on Monday-Thursday from 6:30 AM to 4:00 PM. The examiner can also be reached on alternate Fridays during the same hours.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Safet Metjahic, can be reached on (703) 308-1436. Any inquiry of a general nature or relating to

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the status of this application or proceeding should be directed to the Group receptionist whose telephone number is (703) 308-0956.

PBK

3/14/00

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